IN THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application.

- 1. (Currently amended) A light emitting device comprising:
- a substrate having an insulating surface;
- a first transparent film comprising silicon oxide formed over the substrate;
- a second transparent film comprising silicon oxynitride over the first transparent

film;

- a third transparent film comprising silicon nitride over the second transparent film;
 - a first electrode formed over the third transparent film;
 - a layer including an organic compound formed over the first electrode; and
 - a second electrode formed over the layer including the organic compound,

wherein a refractive index of the second transparent film gradually increases from

[[an]] a first interface at a side of the substrate first transparent film to [[an]] a second

interface at a side of the first electrode third transparent film.

2-3. (Canceled)

4. (Previously presented) The light emitting device according to claim 1, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.

- 5. (Currently amended) A light emitting device comprising:
- a first substrate having an insulating surface;
- a first electrode formed over the first substrate;
- a layer including an organic compound formed over the first electrode;
- a second electrode formed over the layer including the organic compound; [[and]]
- a transparent film comprising silicon oxynitride formed over the second electrode;

and

a second substrate over the transparent film, wherein a gap between the transparent film and the second substrate is filled with a substance,

wherein the substance is an inert gas or a resin, and

wherein a refractive index of the transparent film gradually varies decreases from [[an]] a first interface at a side of the second electrode in a film thickness direction to a second interface at a side of the substance.

6-7. (Canceled)

8. (Previously presented) The light emitting device according to claim 5, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.

- 9. (Currently amended) A light emitting device comprising:
- a substrate having an insulating surface;
- a first transparent film comprising silicon oxide formed over the substrate;
- a second transparent film comprising silicon oxynitride over the first transparent film;
- a third transparent film comprising silicon nitride over the second transparent film;
 - a first electrode formed over the third transparent film;
 - a layer including an organic compound formed over the first electrode; and
 - a second electrode formed over the layer including the organic compound,

wherein the transparent film comprises a plurality of substances which include at least a first substance and a second substance, and

wherein a composition ratio of the second substance to the first substance gradually varies from an interface at a side of the substrate to an interface at a side the first electrode

wherein a composition ratio of oxygen in the second transparent film decreases, while a composition ratio of nitrogen in the second transparent film increases from a first interface at a side of the first transparent film to a second interface at a side of the third transparent film, and

wherein a refractive index of the second transparent film gradually increases from the first interface to the second interface.

10-13. (Canceled)

- 14. (Previously presented) The light emitting device according to claim 9, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.
 - 15. (Currently amended) A light emitting device comprising:
 - a first substrate having an insulating surface;
 - a first electrode formed over the first substrate;
 - a layer including an organic compound formed over the first electrode;
 - a second electrode formed over the layer including the organic compound; [[and]]
- a transparent film <u>comprising silicon oxynitride</u> formed over the second electrode[[,]]; and
- a second substrate over the transparent film, wherein a gap between the transparent film and the second substrate is filled with a substance,

wherein the substance is an inert gas or a resin,

wherein the transparent film comprises a plurality of substances which include at least a first substance and a second substance; and

wherein a composition ratio of the second substance to the first substance gradually varies from an interface at a side of the second electrode in a film thickness direction

wherein a composition ratio of oxygen in the transparent film increases, while a composition ratio of nitrogen in the transparent film decreases from a first interface at a side of the second electrode to a second interface at a side of the substance, and

wherein a refractive index of the second transparent film gradually decreases from the first interface to the second interface.

16-18. (Canceled)

- 19. (Previously presented) The light emitting device according to claim 15, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.
- 20. (Currently amended) A method for manufacturing a light emitting device comprising:

forming a <u>first</u> transparent film <u>comprising silicon oxide</u> over a substrate having an insulating surface;

forming a second transparent film comprising silicon oxynitride over the first transparent film;

forming a third transparent film comprising silicon nitride over the second transparent film;

forming a first electrode over the third transparent film;

forming a layer including an organic compound over the first electrode; and

forming a second electrode over the layer including the organic compound,

wherein the <u>second</u> transparent film is formed so that a refractive index of the transparent film gradually <u>varies increases</u> from [[an]] <u>a first</u> interface at a side of the

substrate first transparent film to [[an]] a second interface at a side of the first electrode third transparent film.

21-22. (Canceled)

- 23. (Previously presented) The method for manufacturing a light emitting device according to claim 20, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.
- 24. (Currently amended) A method for manufacturing a light emitting device comprising:

forming a first electrode over a first substrate having an insulating surface;

forming a layer including an organic compound over the first electrode;

forming a second electrode over the layer including the organic compound;
[[and]]

forming a transparent film <u>comprising silicon oxynitride</u> over the second electrode[[,]];

providing a second substrate over the transparent film; and

filling a substance with at least a gap between the transparent film and the second substrate,

wherein the substance is an inert gas or a resin, and

wherein the transparent film is formed so that a refractive index of the transparent film gradually varies decreases from [[an]] a first interface at a side of the second electrode in a film thickness direction to a second interface at a side of the substance.

25-26. (Canceled)

- 27. (Previously presented) The method for manufacturing a light emitting device according to claim 24, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.
- 28. (Currently amended) A method for manufacturing a light emitting device comprising:

forming a transparent film <u>comprising silicon oxynitride</u> over a substrate having an insulating surface, wherein the transparent film is formed by sputtering using a silicon oxide target and a silicon nitride target;

forming a first electrode over the transparent film;

forming a layer including an organic compound over the first electrode; and forming a second electrode over the layer including the organic compound,

wherein the transparent film comprises a plurality of substances which includes at least a first substance and a second substance, and

wherein the transparent film is formed so that a composition ratio of the second substance to the first substance oxygen in the transparent film gradually varies decreases, while a composition ratio of nitrogen in the transparent film gradually increases from [[an]] a first interface at a side of the substrate to [[an]] a second interface at a side of the first electrode.

29. (Canceled)

30. (Currently amended) The method for manufacturing a light emitting device according to claim 28, wherein the transparent film is formed so that the refractive index of the transparent film gradually increases from [[an]] the first interface at the side of the substrate to the second interface at the side of the first electrode.

31-32. (Canceled)

- 33. (Previously presented) The method for manufacturing a light emitting device according to claim 28, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.
- 34. (Currently amended) A method for manufacturing a light emitting device comprising:

forming a first electrode over a <u>first</u> substrate having an insulating surface; forming a layer including an organic compound over the first electrode;

forming a second electrode over the layer including the organic compound;
[[and]]

forming a transparent film <u>comprising silicon oxynitride</u> over the second electrode, <u>wherein the transparent film is formed by sputtering using a silicon oxide</u> target and a silicon nitride target;

providing a second substrate over the transparent film; and

filling a gap between the transparent film and the second substrate with a substance,

wherein the substance is an inert gas or a resin, and

wherein the transparent film comprises a plurality of substances which includes at least a first substance and a second substance, and

wherein the transparent film is formed so that a composition ratio of the second substance to the first substance nitrogen in the transparent film gradually varies decreases, while a composition ratio of oxygen in the transparent film gradually increases from [[an]] a first interface at a side of the second electrode in a film thickness direction to a second interface at a side of the substance.

35. (Canceled)

36. (Currently amended) The method for manufacturing a light emitting device according to claim 34, the transparent film is formed so that the refractive index of the

transparent film gradually decreases from [[an]] the first interface at the side of the second electrode in the film thickness direction to the second interface.

37-38. (Canceled)

39. (Previously presented) The method for manufacturing a light emitting device according to claim 34, wherein the light emitting device is incorporated in at least one selected from the group consisting of a personal computer, a video camera, a mobile computer, a player using a recording medium, a digital camera, a mobile telephone, and an electronic book.